IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of)	Mail Stop AF
Adrien Dromard et al.	Group Art Unit: 1793
Application No.: 10/583,417	Examiner: Richard M. Rump
Filed: April 26, 2007	Confirmation No.: 3689
For: HIGHLY-STRUCTURED SILICA HAVING A LOW WATER UPTAKE, PREPARATION METHOD THEREOF AND USES OF THE SAME	

AMENDMENT PURSUANT TO 37 C.F.R. §1.116

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

In response to the Office Action dated November 5, 2009, please amend the above-identified patent application as follows: